



Application No. 10/782,782  
Sec.1143  
Response dated 26 January 2005

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent application of :  
Don-Woo LEE et al. : Group Art Unit 2891  
Application No. 10/782,782 : Examiner Asok K. SARKAR  
Filed 23 February 2004 :

METHOD OF FORMING A CONDUCTIVE PATTERN OF A SEMICONDUCTOR  
DEVICE AND METHOD OF MANUFACTURING A NON-VOLATILE  
SEMICONDUCTOR MEMORY DEVICE USING THE SAME

**AMENDMENT AND/OR RESPONSE UNDER 37 C.F.R. § 1.112**

U.S. Patent and Trademark Office  
Customer Window, **Mail Stop Amendment**  
Randolph Building  
401 Dulany Street  
Alexandria, VA 22314

Sir:

In response to the Office Action of 3 October 2005, the period for response to which is hereby extended by the accompanying Petition and Petition Fee through 3 February 2006, reexamination and reconsideration are respectfully requested in view of the following Remarks.

**Remarks** begin on page 2 of this paper.